

# Raman Spectroscopy and Field Emission Measurements on Catalytically Grown Carbon Nanotubes

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*Received: June 28, 2002*

We used microcontact printing to pattern a silicon surface with an iron-containing catalytic solution. Multiwall carbon nanotubes were subsequently grown on the patterned areas by chemical vapor deposition at temperatures between 650 and 1000 °C. We demonstrate that the diameter of the catalytically grown multiwall nanotubes increases with the deposition temperature. Raman spectroscopy has been used to investigate the crystalline character of the obtained structures, and it was found that the fraction of the nanocrystalline shell increases with the temperature. The measurement of the field-emission properties shows a correlation between the tube diameter and the emission-field values.

## Introduction

Carbon nanotubes<sup>1</sup> have been studied for several years and are now considered for applications in miscellaneous devices such as tubular lamps,<sup>2</sup> flat-panel displays,<sup>3</sup> lighting elements,<sup>4</sup> and nanometric electronic devices.<sup>5,6</sup> Such devices make precise demands on the properties of the tubes, as the length, diameter, and electronic properties have a strong influence on the final performance of the device. This implies that the nanotube growth has to be controlled and understood. However, we still lack exact knowledge of the growth mechanism, be it for arc discharge, laser ablation, or catalytic growth.<sup>7</sup>

One of the most promising properties that should be exploited for applications is the very good field emission of the nanotubes.<sup>8</sup> The catalytic deposition is the most practical method to create nanotubes on vast surfaces. In a recent paper, we reported on our study of the deposition conditions of the catalytic growth of multiwalled carbon nanotubes.<sup>9</sup> We found that the catalyst had an influence on the morphology of the grown structures and that Fe was better suited for the low-temperature growth of nanotubes than Ni or Co. We also noted that the diameter of the nanotubes increases with the deposition temperature. We present here advanced investigations on the structures obtained with Fe as a catalyst. We performed Raman and transmission electron microscopy (TEM) studies to elucidate the crystalline structure of these objects. With respect to applications, we also completed the research on these structures with the study of their field-emission properties. We demonstrate that combing field-emission measurements, scanning electron microscopy (SEM), Raman spectroscopy, and TEM allows for an optimization of the crystallinity, geometry, and field emission while gaining new information about the structure of the considered objects.

## Experimental Methods

**Synthesis of Nanostructured Material.** Microcontact printing ( $\mu$ CP) was performed to pattern a (100)-oriented boron-doped silicon wafer (resistivity: 5–25 m $\Omega$  cm).<sup>9</sup> The stamps for  $\mu$ CP were obtained by curing poly(dimethyl)siloxane (PDMS) for at least 12 h at 60 °C on a structured master that was prepared by contact photolithography. The structures of these stamps are squares with a width of 5  $\mu$ m. They were hydrophilized before use by an oxygen plasma treatment (O<sub>2</sub> pressure  $\sim$ 0.8 mbar, load coil power  $\sim$ 75 W, 60 s). The catalyst solution for the  $\mu$ CP was a 100 mM solution of Fe(NO<sub>3</sub>)<sub>3</sub>·9H<sub>2</sub>O in ethanol. The catalyst concentration of 100 mM was chosen because at this concentration a dense but well-separated growth of nanotubes is obtained with good reproducibility.<sup>9</sup> For printing, the stamp was loaded with 0.2 mL of catalyst solution for 30 s and then dried in a nitrogen stream for 10 s. The printing was performed by placing the stamp on the surface of the SiO<sub>2</sub>/Si wafer for 3 s.

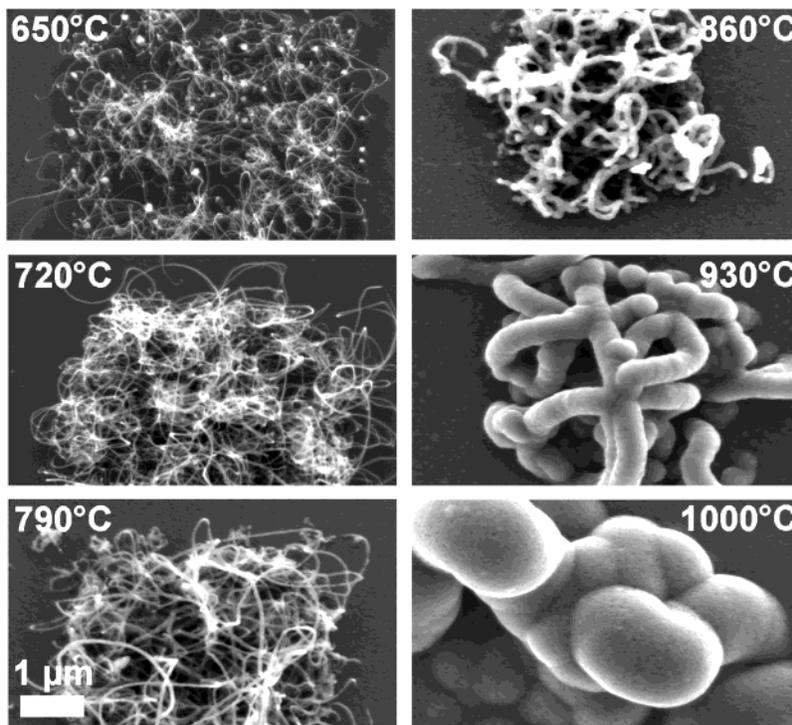
The catalytic growth of nanotubes was carried out in a flow reactor (quartz tube with an inner diameter of 14 mm in a horizontal oven) directly after the printing. Before the deposition, the volume of the quartz tube was rinsed by a nitrogen stream of 80 mL/min. The deposition was performed with 80 mL/min of nitrogen and 20 mL/min of acetylene (carbon source for the catalytic growth) at atmospheric pressure.

**Characterization Techniques.** Scanning electron microscopy (SEM) was performed to analyze the microstructures in plain view. A Philips XL 30 microscope equipped with a field-emission gun (FEG) was used with an acceleration voltage between 3 and 5 kV, a working distance of 10 mm, and in secondary electron (SE) image mode.

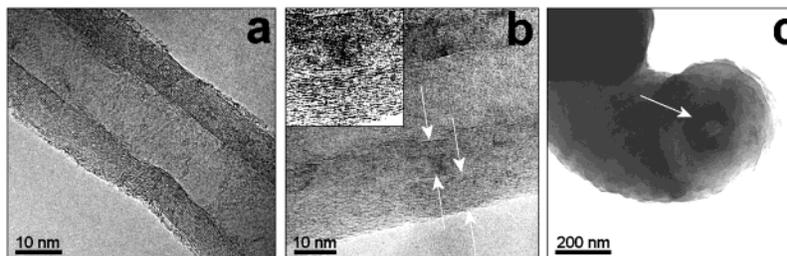
The growth morphology and crystallinity of the tubular structures were controlled by transmission electron microscopy (TEM). For this purpose, a Philips EM 430 microscope equipped with a Gatan image plate operating at 300 kV (point resolution 0.3 nm) was used.

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**Figure 1.** SEM micrographs of carbon structures obtained at deposition temperatures from 650 up to 1000 °C (deposition time: 30 min).



**Figure 2.** (a) TEM micrograph of a section of a carbon nanotube grown at 650 °C. The graphite layers of the hollow multiwall nanotube are well visible. (b) TEM micrograph of a carbon structure grown at 790 °C with a crystalline core and a polycrystalline outer shell. The core and the shell are delimited by arrows. The region of interest is enlarged in the inset. (c) TEM micrograph of a carbon structure grown at 930 °C with an arrow indicating the nanotube core.

Information about the vibrational properties of the nanostructures was obtained by micro-Raman spectroscopy. The Raman spectra were recorded in a backscattering configuration using the 514.5-nm line of an Ar<sup>+</sup> ion laser and a DILOR XY 800 spectrometer. An incident maximum laser power of 20 mW was applied in order to avoid peak shifts due to thermal heating or structure transformations during data acquisition. A spot size of approximately 2 μm was achieved with a 250× Olympus microscope objective. The spectra were calibrated using a natural diamond single crystal.

The field-emission measurements were performed using the examined samples as cathodes. The emitted electrons were collected on a highly polished stainless-steel spherical counterelectrode of 1-cm diameter, which corresponds to an emission area of ~0.007 cm<sup>2</sup>. The distance between the electrodes was adjusted to 125 μm. A Keithley 237 source-measuring unit was used to supply the voltage (up to 1000 V) and to measure the current with pA sensitivity, allowing for the characterization of current–voltage (*I*–*V*) behavior.

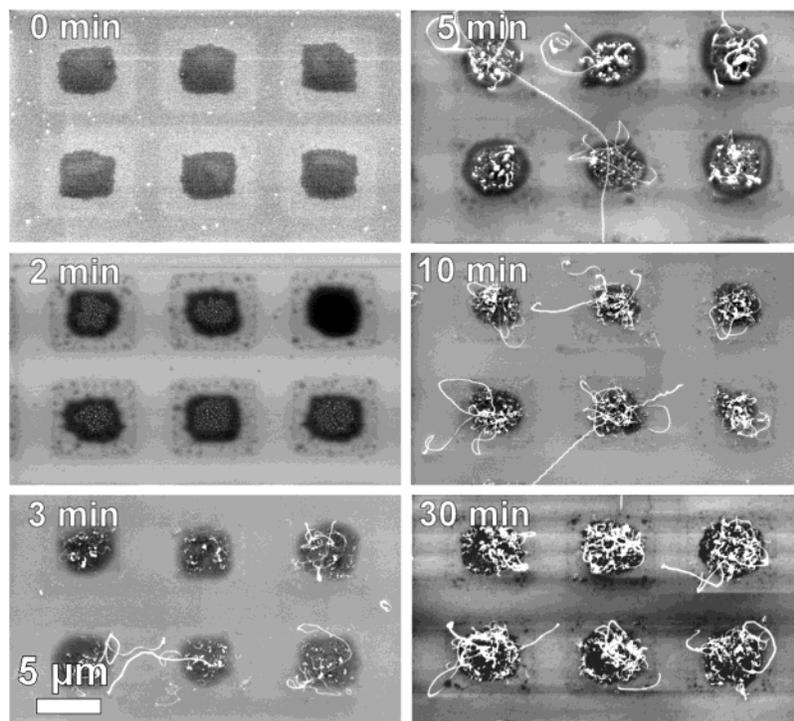
## Results

**Morphology.** The influence of the deposition temperature on the morphology of the carbon structures is demonstrated for

a deposition time of 30 min in Figure 1. The carbon nanotubes and carbon structures grow with a random orientation from iron-inked squares of a silicon surface. One can nicely see the increase of the diameter from thin nanotubes at 650 °C to thick “carbon worms” at 1000 °C. The diameter varies between 25 nm for the structures at 650 °C and about 1 μm for the structures at 1000 °C. TEM reveals that multiwall nanotubes grown at 650 °C are hollow and well-graphitized (Figure 2a). The well-separated nanotubes have an inner diameter of about 15 nm and an outer diameter of about 30 nm. Most of them have open ends, and some nanotubes contain encapsulated catalyst particles. In about 10 percent of the nanotubes, we found these particles at the top of the tube. In this case, the particles are of prolate shape and are aligned in the growth direction.<sup>9</sup>

The carbon structures grown at higher temperatures consist of a “nanotube core” and an additional layer of amorphous or polycrystalline carbon. Figure 2b shows a TEM image of the structures obtained at 930 °C where a core structure is surrounded by flakelike carbon (indicated by arrows in Figure 2b). The structures at 1000 °C are too thick to be imaged by TEM due to the electron transparency.

We also found that the growth of the nanotubes is a very fast process: under our conditions, the growth takes place during



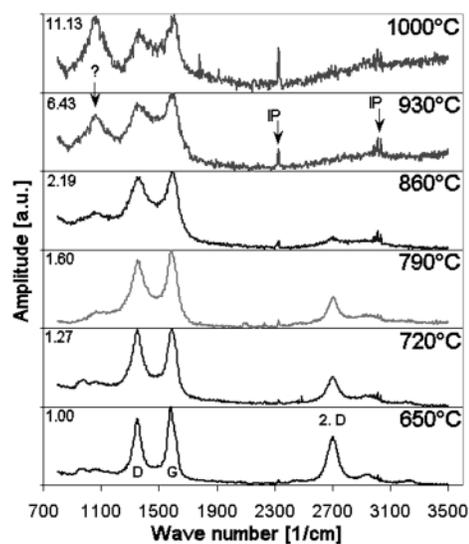
**Figure 3.** Time dependence of the growth of the carbon nanotubes by chemical vapor deposition (deposition temperature: 720 °C).

the first 5 min. Figure 3 shows the evolution of the nanotube growth with time at 720 °C. After the annealing without the CVD process, only the printed catalyst patterns are visible. After 2 min of deposition, some dots of carbonized catalyst appear in the center of the printed squares. Only 1 min later, we detect nanotubes of up to 10  $\mu\text{m}$  length, which implies that the growth rate is of at least 160 nm/s. In the following time, the density of the nanotubes increases, but we cannot detect a significant increase in length. The maximum length remains at about 10  $\mu\text{m}$ .

**Raman Spectroscopy.** We performed micro-Raman spectroscopy in order to investigate the vibrational properties of the synthesized carbon structures, which also allows us to draw further conclusions about their crystallography or morphology. Figure 4 compares the Raman spectra measured from carbon nanotubes grown at temperatures between 650 and 1000 °C. All spectra show at least the two significant peaks at 1580  $\text{cm}^{-1}$  and at 1347  $\text{cm}^{-1}$ , which become broader at higher temperatures and overlap.

Crystalline graphite leads to a sharp vibration mode at 1580  $\text{cm}^{-1}$ ,<sup>10</sup> which is due to the presence of C  $\text{sp}^2$  domains and is named the first-order G band. The peak at approximately 1350  $\text{cm}^{-1}$  is considered to represent a more disordered structure and is labeled as the D (disordered) band.<sup>11</sup> Note that in a perfect graphite crystal the first-order vibrational mode of the D band is forbidden because of the selection rules. Decreasing particle size or bending of the lattice fringes may activate this band. As seen in Figure 4, the second-order D peak (2.D) appears at approximately 2700  $\text{cm}^{-1}$  for nanotubes grown at lower temperatures. However, with increasing deposition temperature, this peak disappears. The spectra are normalized to the highest peak in each spectrum (the G peak). The signal strength gets weaker for the structures deposited at higher temperatures; therefore, the noise level becomes more and more visible in the spectra.

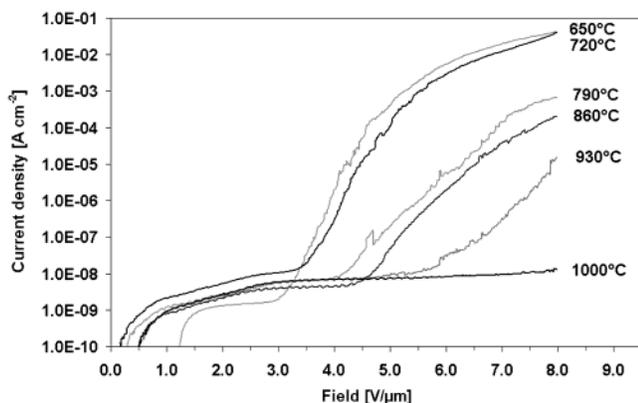
It is known (e.g., in refs 12 and 13) that smaller particles as well as structural imperfections will broaden the first-order peaks from graphite. Therefore, one can estimate the order of



**Figure 4.** Micro-Raman spectroscopy of carbon nanotubes obtained at temperatures between 650 and 1000 °C. The peaks for the disordered (D) and the graphite (G) carbon, the second-order D peak (2.D), and impurity peaks (IP) are visible. On the left side of the spectra, the scaling factors are mentioned (relative to the spectrum at 650 °C). The spectra are normalized to the highest peak (G peak) in each spectrum.

crystallinity in the material from the corresponding half-width (fwhm). An amorphous structure typically leads to a half-width (fwhm) of approximately 200  $\text{cm}^{-1}$ ,<sup>13</sup> as observed in the case of deposition at 1000 °C. In the case of nanotubes deposited at 650 °C, sharp peaks (fwhm  $\sim$ 90  $\text{cm}^{-1}$ ) reveal their much higher degree of crystalline perfection.

The catalytically grown carbon nanotubes can be characterized as a nanocrystalline but disordered graphitelike system where the disorder increases with the preparation temperature. This confirms qualitatively the results obtained by TEM. Unfortunately, Raman measurements could not clearly confirm that the high-temperature carbon structures consist of an amorphous and of a crystalline part, as suggested by TEM.



**Figure 5.** Field emission of the carbon nanotubes. The nanotubes obtained at 650 °C provide the lowest emission-field values.

**TABLE 1: Table of the Field-Emission Values<sup>a</sup>**

temperature (°C)	turn-on field $E_{10}$ (V/ $\mu$ m)	threshold field $E_{thr}$ (V/ $\mu$ m)	field amplification $\beta$
650	4.2	6.4	696
720	4.5	6.8	688
790	6.3		958
860	6.5		751
930	7.9		410
1000			

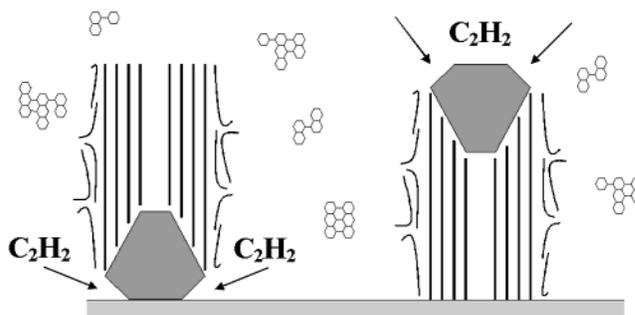
<sup>a</sup> The turn-on field  $E_{10}$  (field at a current density of  $10^{-5}$  A/cm<sup>2</sup>, first illumination of a screen pixel), the threshold field  $E_{thr}$  (field at a current density of  $10^{-2}$  A/cm<sup>2</sup>, saturation of a pixel), and the field amplification  $\beta$  (obtained by calculations based on the Fowler–Nordheim theory) as function of the deposition temperature.

Interestingly, the relative height of the peak at about 1047 cm<sup>-1</sup> increases with temperature. This peak could not yet be identified, but its broad shape indicates that it could probably originate from solid-state phonons. We detected this peak in earlier experiments on nitrogenated carbon nanotubes.<sup>14</sup> Some other peaks as indicated by arrows in Figure 4 might be due to impurities. Stretch vibrations of N<sub>2</sub> in the ambient air might cause the sharp peak at about 2325 cm<sup>-1</sup>.<sup>15</sup>

**Field Emission.** In Figure 5, we present the results of the field-emission measurements of the obtained carbon films. We noted a decrease of the absolute current density at a given applied field with increasing deposition temperature. The turn-on field  $E_{10}$  (field to obtain a current density of  $10^{-5}$  A/cm<sup>2</sup>, first illumination of a screen pixel) and the threshold field  $E_{thr}$  (field at a current density of  $10^{-2}$  A/cm<sup>2</sup>, saturation of a screen pixel) both increase with increasing deposition temperature (Table 1). For the carbon structures deposited at temperatures of 790 °C, values of the current density for the threshold field of  $10^{-2}$  A/cm<sup>2</sup> were not reached below the maximal applied voltage of 1000 V at a 125- $\mu$ m interelectrode distance.

The field-amplification factor was calculated with the Fowler–Nordheim equation. The model describes the electron emission from a flat surface by tunneling through the triangular surface potential barrier. The emitted current  $I$  is proportional to  $F^2 \exp(-B\phi^{3/2}/F)$ , where  $F$  is the applied field just above the emitting surface,  $\phi$  is the work function, and  $B$  is a constant ( $B = 6.83 \times 10^{-9}$  V eV<sup>3/2</sup> m<sup>-1</sup>).<sup>16</sup> Generally,  $F$  is not known exactly and is therefore taken here as  $F = \beta E = \beta V/d$ , with the applied voltage  $V$ , the interelectrode distance  $d$ , and the macroscopic applied field  $E = V/d$ . The work function was assumed to be equal to 5 eV, which is a reasonable assumption for carbon-based field emitters.<sup>17</sup>

The field-amplification values do not follow a simple trend with temperature, as can be extracted from Table 1. It is well



**Figure 6.** Model for the supposed growth mechanism of catalytically grown carbon nanotubes (based on considerations by Kanzow et al.<sup>20</sup>).

known that for a single tube a larger diameter will lower the field amplification factor for a given length. The increase of the diameter found in Figure 1 should thus result in a monotonically decreasing field-amplification factor. Our experimental results suggest that this trend is masked (at least in part) by varying nanotube lengths and nanotube densities on the samples, which lead to more or less pronounced screening effects.<sup>18</sup> The comparison with the SEM images suggest that the field emission corresponds to the geometry of the structures and that the structures with a smaller diameter emit better. This behavior was also observed earlier for nitrogenated carbon structures.<sup>19</sup>

## Discussion

We discuss in the following text our results in light of the most probable growth mechanism for carbon nanotubes under our experimental conditions. Acetylene is stable at temperatures below 800 °C and can only be catalytically dissociated, in our case on the small metal (oxide) particles delivered to the substrate by microcontact printing (Figure 6). The dissociation reaction presumably takes place at facets of well-defined crystallographic orientation, and the resulting hydrogen H<sub>2</sub> is removed by the gas flow whereas the carbon is dissolved in and diffuses into the particle.<sup>20</sup> For unsaturated hydrocarbons, this process is highly exothermic. When the particle is saturated with carbon, the carbon segregates on another less-reactive surface of the particle, which is an endothermic process. The resulting density gradient of carbon dissolves in the particle and supports the diffusion of carbon through the particle. To avoid dangling bonds, the carbon atoms assemble in an sp<sup>2</sup> structure at a less reactive facet of the particle, which leads to the formation of a nanotube.

We noted in Figure 3 that the nanotube growth did not begin immediately after the introduction of the hydrocarbon gas in the reactor but that some carbonized spots appear before the rapid nanotube growth. This suggests that a certain quantity of carbon must be dissolved into and diffuse through the particle before the nanotube growth can start.

The simple model presented in Figure 6 describes the growth with a particle at the top of the nanotube or at the bottom. In the second case, the particle sticks more to the substrate than in the first case. But there must be free particle surfaces that are exposed to the gas to proceed with the growth. In the second case, the acetylene diffuses from the side into the particle, and the nanotube is constructed from the bottom up, whereas in the first case, the gas diffuses from the sides and from the top into the particle. This seems to be the favored mechanism in our case, as typically 90% of the tubes have closed tips without a catalytic particle.

It is at first glance difficult to understand why the diameter of the structures increases with temperatures above 800 °C in

the frame of the above model. At around 800 °C, acetylene starts to dissociate spontaneously, and therefore the reaction gas contains a significant fraction of free carbon, which will form larger aggregates in order to avoid dangling bonds. These carbon flakes, once formed, are carried with the gas flow and may be deposited on the substrate. We therefore propose the following scenario at temperatures above 800 °C: as is the case at lower temperatures, carbon nanotubes of small diameter are formed over the catalyst-patterned areas after an activation period, whereas the growth itself takes place very rapidly. In addition, the flakes are formed in the gas-phase condensate on the substrate and on the formed nanotubes, adding a polycrystalline outer shell over the graphitic inner core. The structures get thicker with temperature because the proportion between dissociated and molecular acetylene in the gas phase increases.

This explanation is supported by the TEM images and Raman spectroscopy, which confirmed the polycrystalline character of these structures. In fact, whereas SEM suggests an amorphous carbon structure on the surface of the grown tubes, TEM reveals a crystalline core structure that is surrounded by a polycrystalline shell (Figure 2b and c). Raman spectroscopy showed that there is a continuous increase of the polycrystalline fraction in the structures, which corroborates the findings. The outer shell becomes thicker with higher temperature starting from the thinnest structures at a temperature of 650 °C.

The results of the field-emission experiments show that the thinnest nanotubes are more efficient field emitters. The field-emission properties (emission fields, field-amplification factor) follow loosely the morphology of the individual tubes, as the emission fields decrease with increasing temperature. It seems, however, that the overall structure of the nanotube film, such as nanotube density and height, plays a role that is more important than the diameter of the structures because of screening effects.

The crystallinity of the nanotubes may also influence the field-emission properties. Because the work function of polycrystalline and graphitic carbon are very similar, the main difference between the two forms is their electrical resistivity, which is lower in the case of well-graphitized carbon. A higher resistivity will lead to higher emission fields, as a voltage drop will appear along the tube, reducing the effective applied field. However, this effect will play a role only at high current densities, and it will have little influence on the low-current part of the  $I-V$  curve. Therefore, significant differences in the turn-on field and field-enhancement factor between well-graphitized and polycrystalline nanotubes of equivalent dimensions are not expected. The major factor that determines the field-emission properties is the nanotube diameter, length, and spacing.

## Conclusions

We have grown carbon nanostructures by thermal CVD with an iron catalyst that was delivered to the Si substrate by

microcontact printing. We noted that the diameter and morphology of the produced structures varied with the deposition temperature, from thin and well-graphitized carbon nanotubes at 650 °C to micrometer-thick fibers at 1000 °C. We used TEM imaging, Raman spectroscopy, and field-emission experiments to investigate in more detail the character of these structures and found that the increase in temperature above 800 °C resulted in the formation of a polycrystalline outer shell over a nanotube core. We suggest that this effect is due to the dissociation of acetylene in the gas phase, which leads to the formation of carbon flakes that are subsequently deposited on the catalytically grown structures.

**Acknowledgment.** We acknowledge The Swiss National Science Foundation (SNF) for financial support. Electron microscopy was performed at the Centre Interdépartemental de Microscopie Electronique (CIME) of EPFL. We are grateful to Heiko Seehofer from Département des Matériaux of EPFL for technical assistance in Raman spectroscopy.

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